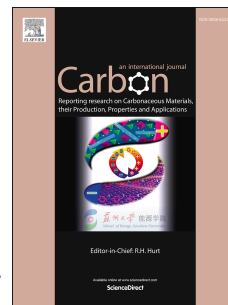


# Accepted Manuscript

High-yield single-step catalytic growth of graphene nanostripes by plasma enhanced chemical vapor deposition

Chen-Chih Hsu, Jacob D. Bagley, Marcus L. Teague, Wei-Shiuan Tseng, Kathleen L. Yang, Yiran Zhang, Yiliang Li, Yilun Li, James M. Tour, N.-C. Yeh



PII: S0008-6223(17)31291-5

DOI: [10.1016/j.carbon.2017.12.058](https://doi.org/10.1016/j.carbon.2017.12.058)

Reference: CARBON 12688

To appear in: *Carbon*

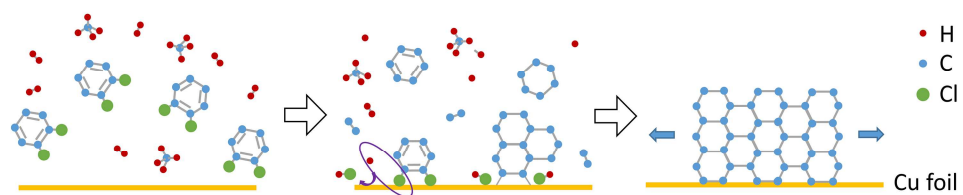
Received Date: 1 November 2017

Revised Date: 14 December 2017

Accepted Date: 15 December 2017

Please cite this article as: C.-C. Hsu, J.D. Bagley, M.L. Teague, W.-S. Tseng, K.L. Yang, Y. Zhang, Y. Li, Y. Li, J.M. Tour, N.-C. Yeh, High-yield single-step catalytic growth of graphene nanostripes by plasma enhanced chemical vapor deposition, *Carbon* (2018), doi: 10.1016/j.carbon.2017.12.058.

This is a PDF file of an unedited manuscript that has been accepted for publication. As a service to our customers we are providing this early version of the manuscript. The manuscript will undergo copyediting, typesetting, and review of the resulting proof before it is published in its final form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers that apply to the journal pertain.



ACCEPTED MANUSCRIPT

Download English Version:

<https://daneshyari.com/en/article/7848939>

Download Persian Version:

<https://daneshyari.com/article/7848939>

[Daneshyari.com](https://daneshyari.com)